Strain-engineered graphene through a nanostructured substrate. I. Deformations

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Using atomistic simulations we investigate the morphological properties of graphene deposited on top of a nanostructured substrate. Sinusoidally corrugated surfaces, steps, elongated trenches, one-dimensional and cubic barriers, spherical bubbles, Gaussian bumps, and Gaussian depressions are considered as support structures for graphene. The graphene-substrate interaction is governed by van der Waals forces and the profile of the graphene layer is determined by minimizing the energy using molecular dynamics simulations. Based on the obtained optimum configurations, we found that (i) for graphene placed over sinusoidally corrugated substrates with corrugation wavelengths longer than 2 nm, the graphene sheet follows the substrate pattern while for supported graphene it is always suspended across the peaks of the substrate, (ii) the conformation of graphene to the substrate topography is enhanced when increasing the energy parameter in the van der Waals model, (iii) the adhesion of graphene into the trenches depends on the width of the trench and on the graphene’s orientation, i.e., in contrast to a small-width (3 nm) nanoribbon with armchair edges, the one with zigzag edges follows the substrate profile, (iv) atomic-scale graphene follows a Gaussian bump substrate but not the substrate with a Gaussian depression, and (v) the adhesion energy due to van der Waals interaction varies in the range [0.1–0.4] J/m\(^2\).

I. INTRODUCTION

Geometrically structured substrates affect various properties of graphene\(^1,2\) and can prevent the crumpling of graphene which is typical for freestanding graphene without a support.\(^3\) Before graphene’s discovery in 2004, the study of 2D membranes over corrugated substrates was an important branch of soft-confined matter physics with, e.g., applications in biological systems.\(^4,5\) Recently, particular attention was focused on the various properties of graphene on top of a substrate. Substrates can induce corrugations, modify the electric conductance, and deform graphene.\(^6,7\) The electrostatic interaction of graphene on a substrate can be understood as due to the van der Waals (vdW) interaction of graphene with the metallic gate below the substrate, the electrostatic forces between graphene and the polarized substrate, the water between the substrate and graphene, and impurities between graphene and the substrate.\(^8\) The vdW interaction includes attractive and repulsive terms, which are widely used and extensively investigated in soft matter.\(^9\) The usual dispersion interaction for the attractive part of the vdW interaction (sum of contributions proportional to \(D^{-6}\)) must be modified for the two \(\pi\)-conjugated systems at distance \(D\), e.g., graphite.\(^10\) For the vdW interaction between carbon nanostructures and Si-C/SiO\(_2\) substrates the Lennard-Jones potential (LJ) is widely used and produced both qualitative and quantitative acceptable results.\(^11-16\) \textit{Ab initio} calculations obtained vdW energy curves between carbon nanostructures (those curves are similar to the LJ function); e.g., the vdW interaction between hexagonal boron nitride sheets,\(^17\) methane adsorption on graphene, and gas molecule adsorption in carbon nanotubes were found to be LJ-like functions when using vdW-corrected density functional theory.\(^18,19\)

Recently, experimental measurements on the adhesion energy of pressurized monolayer/multilayer graphene on top of a SiO\(_2\) substrate showed that the adhesion energy is ultrastrong (\(\chi \sim 0.3–0.45\) J/m\(^2\)) which is many times larger than the one reported for typical micromechanical structures and is of the order of solid-liquid adhesion energies.\(^20\) This adhesion energy is one order of magnitude larger than the upper limit found for water-modified adhesion between graphene and the substrate. Kusminskiy \textit{et al.} used \(\chi = 2\) meV Å\(^{-2}\) for the pinning of a tethered membrane (as a model for graphene within continuum elasticity theory) and found the possible morphology of graphene over a Gaussian bump and a Gaussian depression.\(^21\) Their model includes both bending and stretching energies together with a constant pinning energy.

Here, as distinct from previous works, we investigate graphene on top of several nanostructured substrates with different geometrical deformations. We carried out molecular dynamics simulations at \(T = 300\) K to minimize the energy and find the optimum profile of the deposited graphene membrane. Sinusoidal substrates with different wavelengths, elongated trenches, barriers, bubbles, Gaussian bumps, and Gaussian depressions are considered as geometrical distinct examples of nanostructured substrates. We find that in the case of a sinusoidal substrate with a short wavelength and small energy parameter in the vdW model (i.e., \(\epsilon\)), graphene does not follow the substrate. For graphene on top of the trench, it is found that zigzag graphene falls into the well but armchair graphene is suspended across the trench. The stress distribution shows that the atoms within the deformed parts are highly stressed. For the boundary conditions of the examined graphene flakes we considered both free and supported (i.e., fixed) in-plane boundaries. We found a significant difference in the obtained graphene profile when on top of a Gaussian bump or at a Gaussian depression; i.e., the graphene sheet over a depression with 1 nm variance and 1 nm height does not fall into the depression while it follows a Gaussian bump with the same size. For a Gaussian bump/depression with larger variance, graphene follows both substrates. The square barrier (a cube with 1 nm side) influences graphene such that an unexpected pyramidal shape is found which surrounds the...
barrier. We studied the vdW energy stored between graphene and the nanoscale Gaussian bump by employing a continuum model for both systems and calculated the variation of the vdW energy per area as a function of the energy parameter of the model. We also compared our molecular dynamics results for the Gaussian bump/depression to those predicted by the continuum model and found agreement only in case of a large Gaussian bump with weak interaction, i.e., small $\epsilon$.

This paper is organized as follows. In Sec. II the details of the atomistic model are presented. In Sec. III we present the continuum model for the vdW interaction of graphene and various substrates. In Sec. IV we present results for various nanostructured substrates and different boundary conditions. The results are summarized in Sec. V.

II. ATOMIC MODEL

Classical atomistic molecular dynamics simulation (MD) is employed to simulate large flakes of graphene (GE). The second generation of Brenner’s bond-order potential is employed which is able to describe covalent $sp^3$ bond breaking and the formation of associated changes in the atomic hybridization within a classical potential.22 The Brenner potential terms were taken as

$$E_P = \sum_i \sum_{j>i} \left[ V^R(r_{ij}) - B_{ij} V^A(r_{ij}) \right],$$

where $E_P$ is the average binding energy, and $V^R$ and $V^A$ are the repulsive and attractive terms, respectively. Setting the integer numbers to $\alpha = \beta = m = 4 \text{Eq. (2)}$ gives the 12-6 LJ potential function and for $\alpha = 2, \beta = m = 3 \text{Eq. (2)}$ the 9-6 LJ potential function.23 The minimum of $u(r)$ is $r_{\text{min}} = \sigma (2m)^{1/3m-6}$ which yields $2^{1/6}\sigma$ and $\sigma$ for the 12-6 LJ and 9-6 LJ potential, respectively. Therefore, the equilibrium distance is shorter for the 9-6 LJ potential while the minimum of $u(r)$ ($u_{\text{min}} = -\epsilon$) is the same for both cases. Notice that for the 12-6 LJ potential both attractive and repulsive terms have the same weights in $u(r)$, i.e., $\alpha = \beta$. We will use mostly the 12-6 LJ potential (in some exceptional cases we use the 9-6 LJ potential, which will be mentioned explicitly).

To model the interaction between two different types of atoms such as the carbon atom (C) and a substrate atom (S), we adjust the LJ parameters using the equations $\epsilon_T = \sqrt{\epsilon_C \epsilon}$ and $\sigma_T = (\sigma_C + \sigma)/2$. For carbon we use the parameters to predict correctly the configurations, the hybridization, and the energies for many different hydrocarbon structures.

The carbon-carbon bond length, $a_0$, is 1.42 Å. In our model, the origin of the $xyz$ Cartesian coordinate system is set at (0, 0, 0). Here, the two primitive vectors for the GE latticen, $\mathbf{a}_1 = \sqrt{3}a_0\hat{x}$ and $\mathbf{a}_2 = \sqrt{3}/2a_0\hat{y} + 3/2a_0\hat{z}$, are the two basic vectors of the GE lattice.

In order to model the van der Waals (vdW) interaction between GE and different substrates, we employed the Lennard-Jones (LJ) potential. The LJ potential describes both the repulsive and attractive parts of the vdW energy between two atoms which are nonbonded. The LJ potential is widely used in various simulations.11–16 For two interacting uncharged particles, we have

$$u(r) = \epsilon [\alpha (\sigma / r)^{3\alpha} - \beta (\sigma / r)^{6\beta}],$$

where $r$ is the distance between the two particles, and $\epsilon$ and $\sigma$ are the “energy parameter” and the “length parameter,” respectively. Setting the integer numbers to $\alpha = \beta = m = 4 \text{Eq. (2)}$ gives the 12-6 LJ potential function and for $\alpha = 2, \beta = m = 3 \text{Eq. (2)}$ the 9-6 LJ potential function.23 The minimum of $u(r)$ is $r_{\text{min}} = \sigma (2m)^{1/3m-6}$ which yields $2^{1/6}\sigma$ and $\sigma$ for the 12-6 LJ and 9-6 LJ potential, respectively.

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\( \sigma_C = 3.369 \text{ Å}, \) and \( \epsilon_C = 2.63 \text{ meV}. \) For the substrate atoms we vary \( \sigma \) in the range \((2.5, 3.5) \text{ Å}\) and \( \epsilon \) in the range \((10.0 \text{ meV}, 140.0 \text{ meV})\), where the lower limits are typically for insulators, e.g., SiO\(_2\), and the upper limits are typical for metallic substrates, e.g., Na, K, etc. Notice that the main difference between the two sets of parameters is the energy parameter \( \epsilon \) which is varied over more than one order of magnitude.

The total vDW energy stored between GE with \( N \) atoms and a substrate with \( M \) atoms can be written as

\[
E_{vdW}^A = \sum_{i=1}^{N} \sum_{j=1}^{M} u(r_{ij}),
\]

where \( r_{ij} = |r_i - r_j| \) and \( r_i \) refers to the position of the \( i \)th carbon atom of GE and \( r_j \) refers to the \( j \)th atom of the substrate. Often in MD simulations, one approximates the above sums by including only the nearest-atom in order to reduce the number of interactions. Such an approach is accurate in the case of short-range potentials. Regarding the cutoff distance appropriate for the LJ potential \( r_c = 3\sigma \), only those substrate atoms inside a sphere having radius \( r_c \) with origin at the position of the \( i \)th atom of GE interact most strongly with the \( i \)th atom, while outside this sphere, the interaction strength decreases very fast. Therefore, in practice for each \( i \), the sum over \( M \) can be truncated and limited to the atoms inside a sphere with radius \( r_c \). This is done by employing a neighbor list in our MD simulation. In our study, the number of GE atoms is \( N = 14,400 \) (which is equivalent to a graphene sheet with dimension \( l_x = 19.17 \text{ nm} \) and \( l_y = 19.67 \text{ nm} \)) and the number of substrate atoms is \( M = 6000 \) (only in the case of the Gaussian bump we performed a simulation with \( N = 72,000 \) and \( M = 35,000 \)).

The adhesion energy can be obtained using \textit{ab initio} calculations and can be estimated using classical models (e.g., LJ potential). The present-day patterns of deformation of large-scale GE on top of substrates is beyond reach of traditional \textit{ab initio} methods. Our classical vDW model as based on the LJ potential are able to simulate the realistic sizes and gives a vDW energy (the main term in the binding energy) between two nonbonded systems. Note that several \textit{ab initio} calculations have demonstrated that the vDW interaction between nanoscale objects can be well approximated by a LJ potential.\(^{17-19}\)

The gradient of the total potential energy, i.e., \( E_{\text{total}} = E_p + E_{\text{head}}^A \), is the force experienced by the \( i \)th carbon atom. \( F_i = -\nabla_i E_{\text{total}} \). In common molecular dynamics simulations Newton’s second law should be solved numerically in order to determine the path of motion of the atoms. In this study, the equations of motion were integrated using a velocity-Verlet algorithm with a time step of 0.5 fs and the temperature was held constant at \( T = 10 \text{ K} \) by a Nosé-Hoover thermostat.

The atomic stress experienced by each \( i \)th atom can be expressed as\(^{20,27}\)

\[
\eta_{ij}^{\nu} = \frac{1}{\Omega} \left( \frac{1}{2} m v_i^\nu v_j^\nu + \sum_{j \neq i} r_{ij}^\nu \cdot F_{ij}^{\mu} \right),
\]

where the inner summation is over all the carbon atoms which are neighbors of the \( i \)th atom which occupies a volume \( \Omega = 4\pi a_0^3/3. \) The quantities \( m \) and \( v^\nu \) denote the mass and velocity of the \( i \)th atom and the scaler \( r_{ij}^{\nu} \) is the \( \nu \) component of the distance between atoms \( i \) and \( j \). \( F_{ij}^{\mu} \) is the force on the \( i \)th atom due to the \( j \)th atom in the \( \mu \) direction. We have used this expression to calculate the stress on each atom. In order to be able to visualize the stress distribution on the GE atoms, we colored the atoms according to the value of the dimensionless stresses; i.e., green (red) is related to the minimum (maximum) possible stress.

### III. CONTINUUM APPROACH

Evaluation of the vDW contribution of the stored energy in the deformed GE with average density \( \Sigma_G \), due to the interaction with a substrate with average density \( \Sigma_S \), is obtained after the integration of the vDW potential over both GE and the substrate surfaces. Here, we present for comparative purposes a continuum model for the stored vDW energy between the GE membrane and the substrate. Such an approach can be used to calculate the vDW energy stored between two objects.\(^{4,16,28}\)

In the absence of external pressure, the total free energy of a membrane consists of three terms, i.e., bending, stretching, and vDW terms, which are given by

\[
f = \iint dx \, dy \left[ \tau (\nabla h_G(x, y))^2 + \kappa (\nabla^2 h_G(x, y))^2 \right] + E_{vdW}^C,
\]

where \( \tau \) and \( \kappa \) are the surface tension and the bending rigidity of the membrane, respectively. The two first terms in Eq. (5) are relevant to the bending and stretching energies of GE\(^{21}\) and the third term, \( E_{vdW}^C \), is the total vDW contribution of the interaction between the substrate and the membrane. \( E_{vdW}^C \) includes two repulsive and attractive terms. The stored adhesion energy per area is determined by\(^{5}\)

\[
\chi = \frac{f_{min}}{A} - \tau.
\]

where \( f_{min} \) is the minimum of the total free energy when the membrane takes its optimum configuration. \( A \) is the projected area onto the \( x-y \) plane; i.e., \( A = \iint dx \, dy \). Equation (6) was used by Swain \textit{et al}.\(^{4,5}\) to estimate the adhesion energy of typical soft membranes over different substrates. In Ref. 21 the adhesion part in the free energy was taken as a coupling constant. Assuming a planar local relative height coordinate function for the vDW interaction energy between the substrate and the soft membrane, i.e., the Deryagin approximation, the vDW energy is approximated by

\[
E_{vdW}^C = \iint dx \, dy \left[ V_0 + \psi (\delta h^2) \right].
\]

where \( \psi \) is a function of the height increment \( \delta h = h_G(x, y) - h_S(x, y) \) and \( V_0 \) is a constant. Substituting Eq. (7) in Eq. (5) and minimizing the total free energy with respect to \( h_G(x, y) \) results in the following differential equation: \(^{4,5}\)

\[
(\kappa \nabla^4 - \tau \nabla^2 + v) h_G(x, y) = \psi h_S(x, y),
\]

where \( v \) is proportional to the Hamaker constant \( \epsilon \sigma^6 \Sigma_G \). Equation (8) can be solved in Fourier

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\[ h_G(k) = \frac{h_S(k)}{1 + k^2 \xi_x + k^4 \xi_z}, \]

where \( k \) is the wave vector, \( \xi_x = \tau/v, \) and \( \xi_z = \kappa/v. \) Equation (9) was used to find the optimum configuration of a soft membrane on top of corrugated substrates.\(^{4,5}\)

Here we assume that the vdW energy is not localized and use the LJ potential for the interaction between graphene and the substrate. This gives us the vdW contribution to the adhesion energy, i.e., \( \chi. \) We assume that both substrate and membrane are homogenous and continuous materials. The obvious difference between the atomistic model and the continuum model is the absence of the chirality effect. The LJ potential energy between the \( \Gamma \) membrane and the continuum substrate is given by

\[ E_{vdW}^{GW}(L) = \sum_{n=1}^{L} \sum_{i,j} u_n(r_{ij}). \]

where \( u_n \) is the contribution of the \( n \)th layer and \( L \) is the number of considered substrate layers. For instance, for graphene on top of a Gaussian bump the attractive and repulsive parts are proportional to \( [\rho^2 + (z + n \ell)^2]^{-3} \) and \( [\rho^2 + (z + n \ell)^2]^{-6} \), respectively [here \( \rho(z) \) is the planar (vertical) distance between an atom in graphene and one in the top layer of the substrate], which decrease fast with \( n. \) Recalling the discussion below Eq. (3) we found that [Eq. (11)] for the considered system around the central points \( r \) the top layer \( (n=1) \) contributes almost 99\% of the total energy, the second layer contributes 1\%, and the contribution of the other layers is negligible. This motivated us to restrict our study to the top substrate layer which helps us considerably to minimize the CPU time. Note that for larger \( \Sigma \) and smaller \( \sigma_T \) the contribution of the second layer will increase.

The heights of the graphene and the substrate atoms at each point \( (x,y) \) are denoted by \( h_G(x,y) \) and \( h_S(x,y) \), respectively. The calculations are done for two different boundary conditions: (i) free boundary condition and (ii) supported boundary conditions which prevents in-plane movements for two longitudinal ends of GE. The two atom rows at the longitudinal ends were taken in the zigzag direction (in most cases) and they are allowed to move in the \( z \) direction.

### A. Sinusoidal substrates: Free boundary condition

A sinusoidal deformation of the substrate along the \( x \) direction is given by

\[ h_S(x,y) = h_0 \sin(kx), \]

where \( k = 2\pi/\lambda \) and the amplitude is \( h_0). \) We used different wavelengths, i.e., \( \lambda = 2.3, 4 \) nm, and two sets of \( \sigma \) and \( \epsilon, \) i.e., \( (3.5, 10.0 \) meV) and \( (3.4, 100.0 \) meV), with fixed \( h_0 = 0.5 \) nm. At the start of the simulation, we put a flat graphene sheet on top of this substrate at \( h_G(x,y) = h_S(x,y) + r_{min}. \) We choose the \( x \) direction to be the armchair direction.

After 0.5 \( \) ns of the MD simulation, GE found its optimum configuration which is deformed and corrugated. Figure 1 shows six snapshots of free GE (upper corrugated sheets in each panel) over three different substrates (filled circles in each snapshot). In Figs. 1(a)–1(c) the vdW parameters were set to \( \sigma = 3.5 \) \( \AA, \) \( \epsilon = 10.0 \) meV and in Figs. 1(d)–1(f) the vdW parameters were set to \( \sigma = 3.4 \) \( \AA, \) \( \epsilon = 100.0 \) meV. The wavelength in Figs. 1(a) and 1(d) is 2 nm. Notice that for \( \lambda = 2 \) \( \) nm GE does not follow the substrate, i.e., \( h_G(x,y) \neq h_1 + h_S(x,y), \) where \( h_1 \) is a vertical shift of the order of graphite’s layer distance, i.e., 3.4 \( \) Å. By increasing the wavelength or \( \epsilon, \) GE follows more closely the substrate profile, i.e., \( h_G(x,y) \equiv h_1 + h_S(x,y). \) Increasing \( \epsilon \) yields stronger adhesion and deforms GE (Fig. 2 shows zoomed versions of Fig. 1(c)). Therefore, according to our MD simulations, the shortest wavelength which makes GE’s profile similar to the substrate’s profile is larger than \( \lambda \) = 2 nm. In all figures the colors indicate the stress distribution. Notice that at the

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The filled white circles are the substrate atoms. The parameters in (a), (b), and (c) are \( \sigma = 3.5 \, \text{Å}, \epsilon = 10.0 \, \text{meV} \) and in (d), (e), and (f) are \( \sigma = 3.4 \, \text{Å} \) and \( \epsilon = 100.0 \, \text{meV} \). The wavelengths are \( \lambda = 2 \, \text{nm} \) [(a), (d)], \( \lambda = 3 \, \text{nm} \) [(b), (e)], and \( \lambda = 4 \, \text{nm} \) [(c), (f)]. For the graphene sheet, the colors represent the stress distribution; the highest stress is denoted by red and the lowest by green.

Here we compare our results to those predicted by continuum elasticity theory for a membrane on top of sinusoidal surfaces. The possible solution of Eq. (8)\(^4\) for a membrane on top of a deformation given by Eq. (12) is

\[
h_G(x, y) = \frac{h_0 \sin(kx)}{1 + k^2 \xi_x + k^2 \xi_y}.
\]

For longer wavelengths, or small \( \kappa \) and \( \tau \), this solution gives \( h_G(x, y) \approx h_3(x, y) \) which is in agreement with our MD results for long wavelengths and large \( \epsilon \). For graphene membrane \( \kappa \sim 1.1 \, \text{eV} \) and \( \tau \sim 10 \, \text{eV/Å}^2 \) (taken of the order of the Lamé coefficients) and Eq. (13) is valid if \( v \gg \kappa, \tau \), which are related to both large \( \epsilon \) and \( \Sigma_S \). The stiffer membrane with larger \( \kappa \) and \( \tau \) can not curve easily and stronger adhesion due to a larger \( v \) (i.e., stronger adhesion) is required. By using \( \sigma = (\sigma_C + \sigma_S)/2 = (3.369 + 3.4)/2 \, \text{Å}, \epsilon = \sqrt{2.63 \times 10 \, \text{meV}}, \Sigma_G = 0.225 \, \text{Å}^{-2} \), and \( \Sigma_S = 0.026 \, \text{Å}^{-2} \) yields the Hamaker constant \( \approx 4\pi^2 \epsilon a_b \Sigma_G \Sigma_S = 1.78 \, \text{eV} \) and consequently \( v \sim 0.1 \) and thus \( k^2 \xi_x, k^2 \xi_y \ll 1 \) yield \( \lambda \gg 4.7 \, \text{Å} \) and \( \lambda \gg 5.6 \, \text{Å} \), respectively, which are in agreement with our MD finding, i.e., \( \lambda > 20 \, \text{Å} \).

**B. Sinusoidal substrates: Supported boundary condition**

Here, we impose the supported boundary condition on the longitudinal ends (which is mostly taken to be the zigzag direction). In this case the atoms at \( x = \pm l_x \) are not allowed to move in-plane while they are allowed to move in the \( z \) direction. In this section we use the 12-6 LJ potential with parameters \( \epsilon = 10 \, \text{meV} \) and \( \sigma = 3.4 \, \text{Å} \). We repeated the above simulations by applying the supported boundary condition along the zigzag direction for graphene on top of a substrate with \( \lambda = 4 \, \text{nm} \). Figure 3 shows the optimum configuration of the deposited graphene over this substrate after minimization. Notice that the obtained deformation is different from those for free graphene over the same substrate, Fig. 1(c). The reason is the supported boundary (i.e., fixed in-plane) at the two longitudinal ends. Graphene does not follow the substrate, but the lateral edges (along the \( x \) direction at \( \pm l_x/2 \)) feel a much large stress as compared to Fig. 1(c). Graphene is suspended across the periodic peaks with a small curvature between them. The larger \( \epsilon \) enhances the latter effect. Therefore, the vdW energy is not dominating the bending energy of GE.

**C. Step: Free boundary condition**

The second class of interesting substrate configurations are steps which were recently studied in an experiment to measure the electronic structure and morphology of deposited graphene\(^7\)

\[
h_S(x, y) = h_0 \theta(x),
\]

where \( \theta(x) \) is the Heaviside step function with step height of \( h_0 = 1 \, \text{nm} \) and with \( \Sigma_S \) density of sites. GEs with both armchair and zigzag directions are put on top of the steps.

Figure 4 shows two snapshots of the optimum configurations [an armchair GE with two different directions of view in (a) and (b) and a zigzag GE with two different directions of view in (c) and (d)] of free GEs on top of steps. All GEs follow the steps except around \( x \approx 0 \) where GE is bent.
in a continuous fashion and does not follow the substrate. There are no considerable differences between the optimum configurations of the free armchair [Figs. 4(a) and 4(b)] and free zigzag [Figs. 4(c) and 4(d)] GEs on top of the step. Indeed, the wall atoms at \( x = 0 \) shift (due to adhesion) in both the left and the right parts of the GE toward \( x = 0 \).

D. Step: Supported boundary condition

In Fig. 5 the optimum configuration of GE along the armchair direction with supported boundary condition is shown which is over a sharp step defined by Eq. (14). Notice that there is a significant difference between the deformation obtained here and the one depicted in Fig. 4. The curvature around the step \( (x \approx 0) \) is different and all atoms of GE feel more or less equal stress. The wall at \( x = 0 \) adheres to both the left and the right part of the GE but the supported ends prevent full adhesion of GE to the wall, especially for the right-hand side of GE.

E. Trench: Free boundary condition

The other important substrate that we studied here is an elongated trench

\[
h_3(x, y) = h_0 \theta(x^2 - d^2),
\]

with two walls located at \( x = \pm d = \pm 1.5 \) nm with step height of 1 nm and with \( \Sigma_5 \) density of sites. Figure 6 shows two snapshots of GE on top of such trenches [an armchair GE with two different angles of view in (a), (b), and (c) and a zigzag GE with two different angles of view in (d), (e), and (f)]. After MD minimization zigzag GE follows the trench except around \( x \approx \pm 1 \) nm. In this region, zigzag GE is bent and does not follow the substrate. There is a significant difference between the optimum configurations of armchair [Figs. 6(a) and 6(b)] and zigzag [Figs. 6(d) and 6(e)] GEs. An armchair GE does not follow the trench as well as a zigzag GE. We attribute this effect to the larger number of atoms of zigzag GE (as compared to armchair GE) in the well region \( (|x| \leq d) \), which yields a strong attractive force on the GE atoms due to the substrate atoms within the well’s wall. Recently, Lu et al.\textsuperscript{23} studied wider trenches with \( 2d = 28.6 \) nm using a 9-6 LJ potential in order to find the vdW adhesion of GE membranes. In our study we also used the 9-6 LJ potential and found different deformations as
over the same substrate. Here potential. and 6(d) which show two graphene membranes with free boundaries where both ends were supported in the y plane of the previous ones. An elongated barrier in the parts in the two models. is due to the different strength of both attractive and repulsive compared to the 12-6 LJ potential; see Figs. 6(c) and 6(f). This is due to the different strength of both attractive and repulsive parts in the two models.

F. Trench: Supported boundary conditions

In Fig. 7 we show the optimum configuration of armchair (a) and zigzag (b) graphene with supported boundary condition on top of the trench defined by Eq. (15). There is a significant difference between the deformation obtained here and those depicted in Fig. 6. The curvature for |x| < d is very different and GE atoms around the well feel a lower stress as compared to the one shown in Fig. 6. Here both armchair and zigzag GEs do not follow the substrate and were suspended over the wells which is a consequence of the supported boundaries. Therefore, by controlling the boundary condition one can clearly control the GE deformation over the substrate.

G. Barriers: Free boundary condition

A barrier in the middle of the substrate is the inverse situation of the previous ones. An elongated barrier in the y direction is parameterized as

\[ h_S(x,y) = h_0 \theta(x^2 - d^2), \]

(16)

with two walls at \( x = \pm d = \pm 1.5 \text{ nm} \) with step height of 1 nm and with \( \Sigma_5 \) density of sites. Figures 8(a) and 8(b) show two snapshots of armchair GE (with two different angles of view) on top of the elongated barrier. As we see the stressed regions are located around \( x = \pm d \). GE does not follow the rectangular shape of the barrier in this part.

Another interesting case is the one of a substrate that consists of a cubic barrier in the middle [see the inset (i) in Fig. 8(c)]

\[ h_S(x,y) = h_0 \theta(x^2 - d^2)\theta(y^2 - d^2), \]

(17)

with four walls at \( x,y = \pm d = \pm 1 \text{ nm} \) with step height of 1 nm and with \( \Sigma_5 \) density of sites. Figures 8(c) and 8(d) show that the optimum configuration is pyramidal shaped [inset (ii) shows this schematically]. This particular deformation is due to the four corners of the cube which strongly repel the GE. The highest stresses are distributed around the steps (red colors in the \( x^2 + y^2 \leq 3d \)). The C-C bond lengths in GE are distributed nonuniformly [Fig. 8(e)] but still around the barrier we have a larger stretch in the bond lengths (up to \( \pm 0.147 \text{ nm} \) which are shown by red colors).

H. Barriers: Supported boundary conditions

Figure 9 shows the optimum configuration of armchair GE in the case of supported boundary condition over two different barriers [defined by Eqs. (16) and (17)]. As we see the stress distribution and the deformations are completely different from those shown for free graphene (see Fig. 8).

I. Spherical bubble: Free boundary condition

The next important type of deformation for the substrate that has been realized experimentally\textsuperscript{30,31} is a bubble [see...
From the center [see Fig. 10(a)]. Results in a much larger stressed GE which influences regions edges were supported in the graphene sheet over an bubble with $h_S$ graphene over an elongated barrier of size $10 \text{ meV}$ and graphene with free boundaries over the same substrate). Here $\epsilon = 10 \text{ meV}$ and $\sigma = 3.4 \text{ Å}$ for 12-6 LJ potential.

Fig. 10(b)] which we model by

$$h_5(x, y) = \sqrt{R^2 - \rho^2} + h_1,$$  \hspace{1cm} (18)

where $R$ is the radius of the bubble and $\rho^2 = x^2 + y^2$. In order to create a uniform discrete atomistic structure for the bubble, we set $h_1 = -R/2$. Figures 10(a) and 10(c) show the obtained optimum configuration from MD simulation for the GE on top of a bubble with $R = 2 \text{ nm}$. The optimum configuration is a Gaussian. In order to produce uniform bubbles, we increased the density of lattice sites in the bubble location where $\Sigma = 1/4 \text{ Å}^{-2}$. Increasing the number of lattice sites on the bubble results in a much larger stressed GE which influences regions far from the center [see Fig. 10(a)].

**J. Spherical bubble on the substrate: Supported boundary condition**

The optimum configuration for the supported graphene over a bubble substrate is shown in Fig. 11. Due to the supported ends GE elongates longitudinally along the supported direction; see inset in Fig. 11.

**K. Gaussian bump/depression: Free boundary conditions**

There have been already a few studies that evaluated different properties of a GE membrane in the presence of a bubble substrate is shown in Fig. 11. Due to the supported ends GE elongates longitudinally along the supported direction. Here $\epsilon = 10 \text{ meV}$ and $\sigma = 3.4 \text{ Å}$ for 12-6 LJ potential.

Gaussian deformation, but those studies did not address the following issues: (i) the creation of the Gaussian deformation in GE using an atomistic-scale deformed substrate; (ii) the question of what are the effects of the vDW energy strength on both the deformation and the adhesion energy at the atomistic scale; (iii) the question of what are the important differences between the deformation due to a bump and due to a depression on the atomistic scale, and (iv) the question of what is the effect of the boundary condition on GE.

The Gaussian bump (protrusion)/depression$^{21,32}$ are parameterized as [Fig. 12(b)]

$$h_{5}(x, y) = \pm h_{0} \exp(-\rho^2/2\gamma^2),$$  \hspace{1cm} (19)

where $+h_0$ ($-h_0$) is the height (depth) of the Gaussian bump (depression), $\rho^2 = x^2 + y^2$, and $\gamma$ is the variance of the Gaussian. Kusminskiy et al. studied recently the pinning of GE over a Gaussian bump in order to find the corresponding attachment/detachment of GE.$^{31}$ Our model is more realistic with relevant length scales for both height and variance of the bumps/depressions. Figure 12(a) shows a snapshot of the optimum configuration of a GE on top of the Gaussian bump.

FIG. 10. (Color online) (a) The optimum configuration of the graphene sheet over a bubble with $h_5(x, y) = \sqrt{R^2 - \rho^2} - R/2$ deformation ($R = 2 \text{ nm}$). The corresponding substrate is shown in (b). In (c) we show both the GE and the substrate. For a graphene sheet, the colors indicate the stress distribution. The highest stress is shown by red color and the lowest by green. The substrate atoms are indicated by filled white circles below graphene.
deformation. (b) Variation of the vdW energy versus the radius (in log scale) measured from the origin (0, 0). Results are presented for both molecular dynamics simulation [MD, Eq. (3)] and continuum model [CM, Eq. (10)]. Here the energy parameter in the LJ potential was set to 10 meV (in the inset we took 140 meV) and $\sigma = 3.4$ Å. The substrate is a Gaussian bump with $10 \exp(-r^2/200)$ (Å) deformation. (b) Variation of the vdW energy versus the radius ($r$) for wider Gaussian bump/depression with $10 \exp(-r^2/900)$ (Å) deformation with $\epsilon = 10$ meV and $\sigma = 3.4$ Å.

Figure 12(c) shows the optimum configuration of GE (found from MD) on top of a depression with $h_0 = -1$ nm and $\gamma = 1$ nm. As we see the deformation of the GE over the Gaussian bump is different from the one over the depression (while both have the same variance, heights, and potential parameters, i.e., $\epsilon = 10.0$ meV and $\sigma = 3.4$ Å). This is clear from the curves shown in Fig. 13 which were taken along $x = 0$ and $y = 0$ [corresponding to the deformations shown in Figs. 12(a) and 12(c)]. The optimum configuration of GE on top of the depression [Figs. 13(c) and 13(d)] is not a Gaussian, i.e., $h_S(x, y) \neq h_1 + h_G(x, y)$, because of the stronger repulsive force inside the depression due to the interaction between GE and the substrate. The bond length distribution is shown in Fig. 14.

Figure 15 shows the variation of both $E_{vdW}^A$ (MD) [Eq. (3)] and $E_{vdW}^C$ (CM) [Eq. (10)] versus the radius, $r$, where $r$ is the upper limit of the integrals in Eq. (10). In Fig. 15(a), we set $\gamma = h_0 = 1$ nm, $\epsilon = 10$ meV, and $\sigma = 3.4$ Å, which are close to the one for the SiO$_2$ substrate. For the substrate with a bump the energies of the atomistic model (MD) are close to the one obtained from the continuum model (CM). For the depression, our MD results are different from the continuum model results, which is a consequence of the different profiles.

\[ h_S(x, y) \approx h_1 + h_G(x, y) \]

The red colors refer to the highest stresses which are mostly located around the bump region, $r \leq 2\gamma$. For this size of the bump, GE follows the Gaussian bump, i.e., $h_S(x, y) \approx h_1 + h_G(x, y)$, where $h_1$ is a vertical shift which is about graphite’s layer spacing 3.4 Å.
in GE and the substrate (see Fig. 13). Notice that the used profile in CM for graphene on top of a depression is a Gaussian profile (compatible with the substrate profile) while the found optimized profile in the MD simulation as seen from Figs. 13(c) and 13(d) is not a Gaussian. Therefore, there is a significant deviation from the CM and MD results for depression as shown in Fig. 15(a). In the inset of Fig. 15(a), which is related to graphene on top of a bump, we set the energy parameter to $\epsilon = 140 \text{meV}$. When the energy parameter is large, the results of MD and CM deviate, which is related to the strong attraction between the substrate and GE.

Figure 15(b) shows the vdW energy for a Gaussian bump/depression with larger variance, i.e., $\gamma = 3 \text{nm}$ and $h_0 = 1 \text{nm}$, $\epsilon = 10 \text{meV}$, and $\sigma = 3.4 \text{Å}$. There is good agreement between the results of MD simulations and those found from the continuum model (CM). We conclude that for large variance the continuum model provides a vdW contribution to the adhesion energy which is comparable to the MD atomistic results. But for small bump/depression the CM model is not applicable and the lattice structure of GE should be taken into account.

In Fig. 16 the variations of $\chi = E_{\text{vdW}}^C / A$ versus $\epsilon$ for various $\sigma (= 2.5 \text{Å}, 3.5 \text{Å})$ are shown. Here, graphene is deposited on top of a Gaussian bump with $\gamma = 1 \text{nm}$ and $h_0 = 1 \text{nm}$ where $r = r_0 = 2 \text{nm}$ and the area is calculated using $A = \pi r_0^2 = 4\pi \text{nm}^2$. In Fig. 16(a) and Fig. 16(b) we used the 12-6 LJ and the 9-6 LJ potential parameters, respectively. The 9-6 LJ potential gives results that have larger $|\chi|$ for a particular $\epsilon$ (notice that in this paper the 9-6 LJ potential is used only for comparative purposes).

The energy per area, i.e., $\chi$, is in the range of the adhesion energy found for a graphene membrane positioned on top of a cubic barrier shows an unexpected pyramidal shape. graphene does not follow the substrate. A graphene sheet on top of a cubic barrier shows an unexpected pyramidal shape. It is found that for large Gaussian bump/depression the van der Waals adhesion energy per area for a nanoscale Gaussian bump is found to be around 0.1–0.35 J/m$^2$ depending on the energy parameter of the model.

L. Gaussian bump/depression: Supported boundary conditions

Since the optimum configuration of supported graphene over a Gaussian bump is similar to the one for a spherical bubble, we will not report them here. For supported graphene over a Gaussian depression the optimum configuration is not Gaussian, similarly as for free graphene over a depression (we do not show the optimum configuration here).

V. SUMMARY

We carried out several molecular dynamics simulations and studied systematically the optimum configuration of large-scale graphene deposited on top of several differently shaped substrates. The stress distribution in graphene shows that highly stressed atoms are located around the deformed regions of the substrate.

For short wavelength ($\lesssim 2 \text{ nm}$) graphene is suspended across the neighbor peaks of the sinusoidal substrate and thus graphene does not follow the substrate. A graphene sheet on top of a cubic barrier shows an unexpected pyramidal shape. It is found that for large Gaussian bump/depression the van der Waals contribution in the adhesion energy is in agreement with the prediction of the continuum model. The van der Waals adhesion energy per area for a nanoscale Gaussian bump is found to be around 0.1–0.35 J/m$^2$ depending on the energy parameter of the model.

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